

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

JC996 U.S. PTO  
10/07/2002  
02/07/02  


In re Application of: ) PATENT APPLICATION  
Inventors: Wei-Wei Zhuang and Sheng ) #2  
Teng Hsu ) IDS  
Serial No.: Not Yet Assigned ) 4/10/02  
Filed: Herewith )  
Title: DEVICE AND METHOD FOR )  
REVERSIBLE RESISTANCE )  
CHANGE INDUCED BY )  
ELECTRIC PULSES IN NON- )  
CRYSTALLINE PEROVSKITE )  
UNIPOLAR PROGRAMMABLE )  
MEMORY )  
\_\_\_\_\_  
)

Honorable Commissioner for Patents  
Washington, D.C. 20231

**INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. §1.97**

Sir:

Listed on attached Form PTO-1449 is information submitted pursuant to  
37 C.F.R. §1.56. A copy of each listed publication is submitted herewith.

Applicant respectfully requests that the listed information be considered by  
the Examiner and made of record in the above-identified application.

(Date) 4/5/02

Respectfully submitted,

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**LIST OF PRIOR ART CITED  
BY APPLICANT**

(use as many sheets as necessary)

Sheet 1 of 1 Attorney Docket No. SLA.0622

30996 U.S. PRO  
10/07225  
02/07/12

## U.S. PATENT DOCUMENTS

## OTHER PRIOR ART -- NON PATENT LITERATURE DOCUMENTS

| Examiner Initials | Cite No. <sup>1</sup> | Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, country where published, source. | T <sup>2</sup> |
|-------------------|-----------------------|---|----------------|
|                   |                       | <i>Liu et al., Electric-pulse-induced reversible resistance change effect in magnetoresistive films, Applied Physics Letters, Vol. 76, No. 19; May 8, 2000, pp 2749-2751</i>  |                |
|                   |                       |   |                |
|                   |                       |   |                |

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|-----------------------|--|--------------------|--|
| Examiner<br>Signature |  | Date<br>Considered |  |
|-----------------------|--|--------------------|--|

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

<sup>1</sup>Unique citation designation number. <sup>2</sup>See attached Kinds of U.S. Patent Documents. <sup>3</sup>Enter Office that issued the document, by the two letter code (WIPO Standard ST.3). <sup>4</sup>For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. <sup>5</sup>Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.1<sup>6</sup> if possible. <sup>6</sup>Applicant is to place a check mark here if English language Translation is attached